

L Number	Hits	Search Text	DB	Time stamp
29	383	batch same ("work piece" or wafer) same vacuum	USPAT; EPO; JPO; IBM_TDB	2003/07/30 15:11
30	843	(batch or cassette or boat) same ("work piece" or wafer) same vacuum	USPAT; EPO; JPO; IBM_TDB	2003/07/30 15:15
31	738	batch and station and ("work piece" or wafer) and vacuum	USPAT; EPO; JPO; IBM_TDB	2003/07/30 15:12
32	293	(batch and station and ("work piece" or wafer) and vacuum) and computer	USPAT; EPO; JPO; IBM_TDB	2003/07/30 15:12
33	48	(batch adj size) and ("work piece" or wafer) and vacuum and (etch\$3 or deposit\$3 or clean\$3)	USPAT; EPO; JPO; IBM_TDB	2003/07/30 15:14
34	19220	(batch or cassette or boat) and ("work piece" or wafer or substrate) and (vacuum or subatmospheric)	USPAT; EPO; JPO; IBM_TDB	2003/07/30 15:16
35	2238	(batch or cassette or boat) same ("work piece" or wafer or substrate) same (vacuum or subatmospheric)	USPAT; EPO; JPO; IBM_TDB	2003/07/30 15:16
36	311	((batch or cassette or boat) same ("work piece" or wafer or substrate) same (vacuum or subatmospheric)) and 438/\$.ccls.	USPAT; EPO; JPO; IBM_TDB	2003/07/30 15:17